

CNI v2.0

Desktop nanoimprint tool

Nanoimprint has never been more simple

Featuring

- Thermal nanoimprint (up to 200°C)
- UV nanoimprint (365 nm)
- Imprint in vacuum (0.1 mbar)
- Plug and play



The CNI v2.0 is a very flexible nanoimprint tool. It offers thermal and UV nanoimprint and imprinting in vacuum if needed. The system is built from modules that makes it very flexible to configure for specific needs and to store away when not in use. It handles all shapes and formats of stamps and substrates up to Ø100 mm (4-inch). The system has manual loading and unloading of stamp and substrate but all processing are fully automatic and the dedicated software gives the user full control of the imprint process.

See more at www.nilt.com/cni or contact us at contact@nilt.com to learn more

We develop and deliver micro and nanostructures to the world's high tech leaders – meeting demands at the highest level.



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